Hydrogen Dissociation on Palladium-Sulfide Surfaces

James B. Miller^{1,2*}, Dominic Alfonso¹, Bryan D. Morreale¹ and Andrew J. Gellman^{1,2}

¹ National Energy Technology Laboratory, Pittsburgh, PA 15236 (USA)

² Department of Chemical Engineering, Carnegie Mellon University,

Pittsburgh, PA 15213 (USA)

*jbmiller@andrew.cmu.edu

Introduction

Dense, Pd-based membranes have received significant attention for separation of H_2 from mixed gas streams, such as syngas produced from coal. Pd readily adsorbs and dissociates molecular hydrogen and subsequently allows rapid transport of the hydrogen-atoms through its bulk. Recombination of hydrogen-atoms on the opposite surface of the membrane and desorption of molecular hydrogen completes a sequence that effectively separates hydrogen from all other components of the mixed gas stream [1].

Exposure of the metallic membrane to sulfur gases, such as H_2S , can reduce transport rates by poisoning the ability of the surface to dissociate hydrogen and/or by reacting with the membrane to form a metal-sulfide layer that impedes H-atom diffusion through the bulk. Our previous reports of non-zero hydrogen transport through a palladium membrane with a Pd_4S scale layer suggest that the Pd_4S surface itself is active for hydrogen dissociation [2, 3]. The goal of this work is to acquire a fundamental understanding of hydrogen dissociation on the Pd_4S surface by experimentally characterizing its composition and applying the first-principles Density Functional Theory (DFT) method to examine dissociation pathways and energetics. We demonstrate that Pd_4S surfaces can possess significant dissociation activity, suggesting that low rates of H-atom diffusion through the Pd_4S bulk may limit overall transport rates in the separation application.

Materials and Methods

A 100 micron thick Pd foil was converted to Pd₄S by exposure to H₂S at 650 C. The product Pd₄S foil was mounted in a stainless steel ultrahigh-vacuum (UHV) chamber (10^{-10} torr base pressure) for analysis by Angle Resolved X-ray Photoemission Spectroscopy (AR-XPS) and Low Energy Ion (He⁺) Scattering Spectroscopy (LEISS). AR-XPS provides information on the composition depth profile within the near-surface region, ~5-10 atom layers. LEISS probes composition of the top-surface.

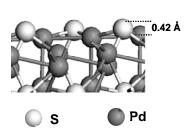
We employed DFT coupled with concepts from thermodynamics to investigate the relative stability of the low-index Pd_4S surfaces [4,5]. The Nudged Elastic Band (NEB) technique was used to examine the pathways for H_2 dissociation on the surfaces [6].

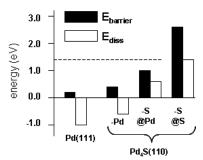
Results and Discussion

AR-XPS results confirm Pd:S = 4:1 stoichiometry in the near-surface region of the sulfided palladium—about 5-10 atom layers. LEISS analysis suggests that the top-layer may be slightly enriched in S relative to the rest of the near-surface. DFT calculations show that, for each of the Pd₄S low-index planes (111, 100, 110, 001), an "S-terminated" variant—in which S

atoms reside slightly above surface Pd atoms (for example, Figure 1 illustrates the sulfur-terminated Pd₄S(110) surface)—is most stable.

Dissociation energies and barrier heights to dissociation were calculated for the low-index Pd_4S terminations. Results for $Pd_4S(110)$, which are typical for all Pd_4S terminations, are compared to clean Pd(111) in Figure 2. Relative to Pd(111), dissociation barriers and energies are less favorable for both the S-terminated ("-S") and Pd-terminated ("-Pd") surfaces of $Pd_4S(110)$. Dissociation energetics on the S-terminated faces depend significantly on reaction pathway: a mechanism in which H_2 interacts primarily with surface Pd atoms ("@Pd") is more favorable than one in which H_2 interacts with surface S atoms ("@S").





 $\begin{array}{llll} \textbf{Figure 1.} & Side & view & of & the & S-\\ terminated & Pd_4S(110) & surface. \\ Topmost S & atoms & reside & above & the \\ plane & of & topmost Pd & atoms & \end{array}$

Figure 2. Energy diagrams for H_2 dissociation on Pd(111) and Pd₄S(110) surfaces. Dotted line shows TST-estimation of the "critical" barrier height for the separation application

For reference, the dissociation barrier height at which dissociation becomes the rate-limiting step in the dissociation-H-diffusion separation sequence, estimated by Transition-State Theory (TST), is shown as the dotted line in Figure 2. Reaction paths having E_{barrier} lower than the "rate-limiting" value exist on both the Pd- and S-terminated Pd₄S surfaces, demonstrating the possibility that low rates of H-atom diffusion through the Pd₄S bulk, and not dissociation rates, limit overall transport rates in the separation application.

Significance

These results contribute to the basis for rational design of poison-tolerant dense metal H_2 purification membrane systems and to understanding of Pd-catalysis in general.

References

- Paglieri, S.N. and J.D. Way, Separation And Purification Methods, 2002. 31(1): p. 1-169.
- 2. Morreale, B.D., *The influence of H2S on palladium and palladium-copper alloy membranes*, 2006, University of Pittsburgh.
- 3. Morreale, B.D., et al., *J. Membrane Sci.*, 2004, **241**(2); p. 219-224.
- 4. Kresse, G. and J. Hafner, *Phys. Rev. B*, 1994. **49**: p. 14251.
- 5. Kresse, G. and J. Fürthmuller, Phys. Rev. B, 1996. 54: p. 11169.
- 6. Henkelman, G., B.P. Uberuaga, and H. Jönsson, J. Chem. Phys., 2000. 113: p. 9901.